



UvA-DARE (Digital Academic Repository)

A virtual reactor for simulation of plasma enhanced chemical vapor deposition

Krzhizhanovskaya, V.V.

Publication date
2008

[Link to publication](#)

Citation for published version (APA):

Krzhizhanovskaya, V. V. (2008). *A virtual reactor for simulation of plasma enhanced chemical vapor deposition*.

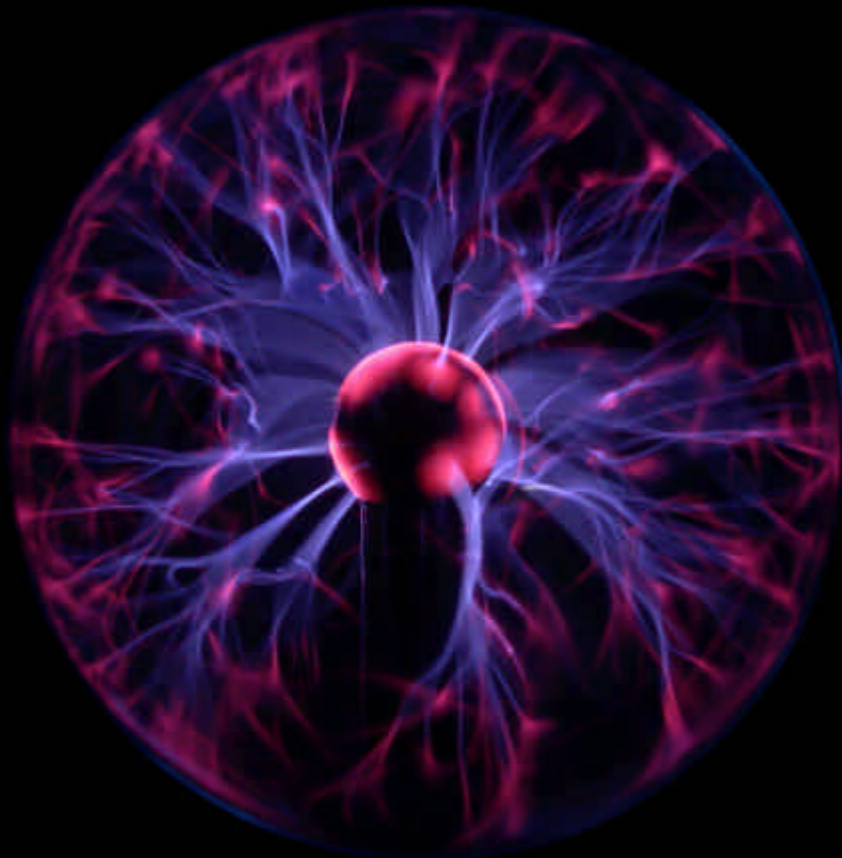
<http://www.science.uva.nl/research/scs/papers/archive/Krzhizhanovskaya2008a.pdf>

General rights

It is not permitted to download or to forward/distribute the text or part of it without the consent of the author(s) and/or copyright holder(s), other than for strictly personal, individual use, unless the work is under an open content license (like Creative Commons).

Disclaimer/Complaints regulations

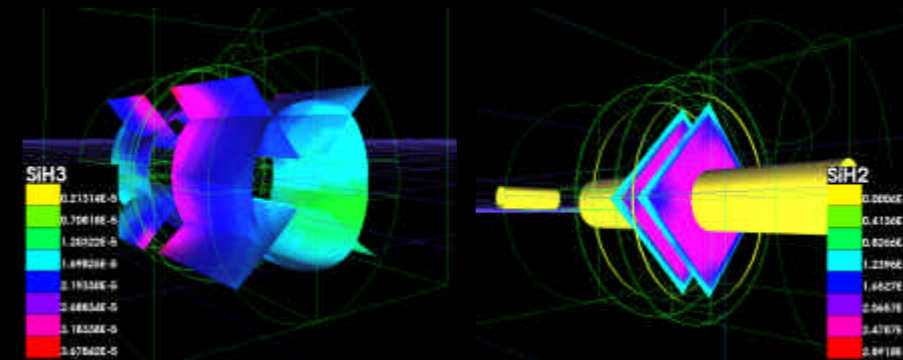
If you believe that digital publication of certain material infringes any of your rights or (privacy) interests, please let the Library know, stating your reasons. In case of a legitimate complaint, the Library will make the material inaccessible and/or remove it from the website. Please Ask the Library: <https://uba.uva.nl/en/contact>, or a letter to: Library of the University of Amsterdam, Secretariat, Singel 425, 1012 WP Amsterdam, The Netherlands. You will be contacted as soon as possible.



A Virtual Reactor for Simulation of Plasma Enhanced Chemical Vapor Deposition

Valeria Krzhizhanovskaya

A Virtual Reactor for Simulation of Plasma Enhanced Chemical Vapor Deposition



Valeria Krzhizhanovskaya

Invitation

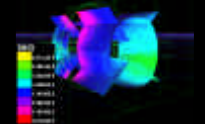
to attend the public
defense of my Ph.D. thesis

A Virtual Reactor for
Simulation of Plasma
Enhanced Chemical Vapor
Deposition

Friday, 20 June 2008
12:00

Agnietenkapel

Oudezijds Voorburgwal 231
Amsterdam



There will be a reception
after the ceremony

Valeria Krzhizhanovskaya
valeria@science.uva.nl